Supporting Information

Effect of medium pressure ultraviolet/chlorine advanced oxidation on the production of disinfection by-products from seven model benzene precursors

Wanting Li [a], Shihu Shu[#a], Yanping Zhu[a,*], Linjing Wu [a], Qiongfang Wang [b], Naiyun Gao [c]

[a] College of Environmental Science and Engineering, Donghua University, Shanghai 201620, China

[b] College of Chemistry and Chemical Engineering, Shanghai University of Engineering Science, Shanghai 201600, China

[c] State Key Laboratory of Pollution Control Reuse, Tongji University, Shanghai 200092, China

*Corresponding author.

E-mail: yanpingzhu@dhu.edu.cn

Lists of Captions

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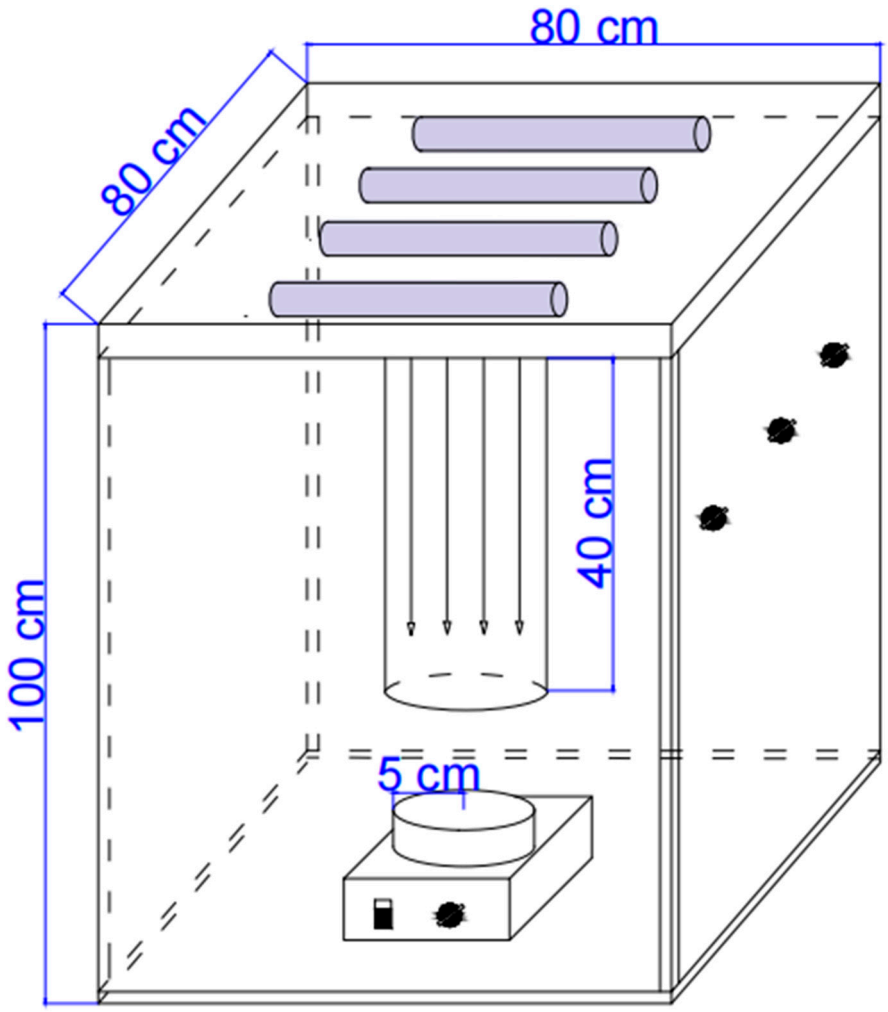
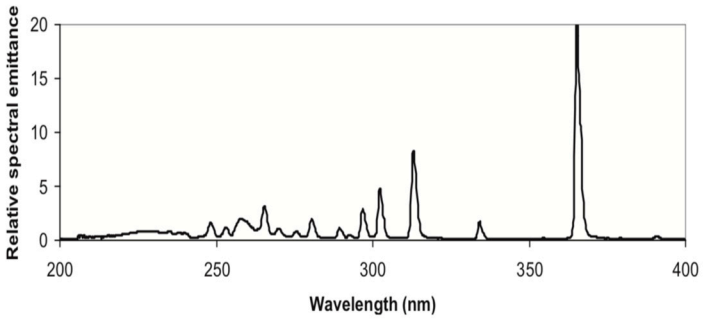
Table S1. Chlorine decay during 60 s pre-oxidation of the seven model compounds.

Model precursors	pH 6 (mg Cl/mg C)				pH 8 (mg Cl/mg C)			
	Ambient		Bromide-spiked		Ambient		Bromide-spiked	
	Cl_2 alone	UV/Cl_2	Cl_2 alone	UV/Cl_2	Cl_2 alone	UV/Cl_2	Cl_2 alone	UV/Cl_2
BA	0.05	0.37	0.01	0.38	0.02	0.96	0.01	0.98
NB	0.01	0.33	0.01	0.30	0.01	0.63	0.01	0.66
PN	0.13	0.93	0.12	0.98	0.2	1.34	0.24	1.47
RSC	3.34	3.38	3.30	3.37	3.30	3.37	3.30	3.37
2-MCP	0.23	1.07	0.53	1.37	0.27	1.53	0.55	1.65
4-MCP	0.10	1.33	0.08	1.57	0.13	1.73	0.17	1.83
2,4,6-TCP	0.20	0.70	0.23	1.37	0.17	1.15	0.21	1.37



(a)



(b)

Figure S1. Schematic diagram of the ultraviolet collimated beam apparatus (a) and spectrogram of a medium-pressure mercury lamp (b).